a) Let vate af foutliele manument (R) by déffusion ie directly propositional to concentration (c) gradient
R & olc If è concentration is not uniform, there will be an è diffusion unuent, which is frestational to the gradient of electron concentration. In dig & dn dx => Jndij = -eDn dn dx In diff -> diffusion auaunt of electrons n -> election cone. un semiconductor C-5 charge of electron Dr -> clectur diffusion constant My, hales diffusion aument $U_{p,diy}$) in semiconductor with shales cone of is. Jp, dig = -e Dp dp dx duhere De vieserente hale diffusion constant Duigt lument. The wount density due to diept, Jdip, is defined as charge for second weeking wint area plane normal to direction of wount flow. Name: Ragini Shauma 10 % B120062

If a sufusion to concentration and $\vec{v}_{d,n}$ is electron disper valously, then disper consent density due to electrons (\vec{J}_n, duy) is

: Jdy = e (4nn + 4pp) E

Current Denity

$$J_n = J_n duy + J_n diy$$

= enun $f_x + eD_n \frac{dn}{dx}$

Naw, Total current density, $J = J_n + J_p$

= enunEx + eDn dn + epupEx - eDp dp

Today

Mame 1 Rogini Shauma 10 : B12 0062

$$= -nu_n \epsilon_x = D_n \frac{dn}{dx}$$

$$=$$
 $\beta_{un}E_{x}=D_{p}\frac{dp}{dr}$ $=$ $=$ $=$ $=$

the know explusion for electron cone n, in conduction band ie

$$h = N_e \cdot e = \frac{(E_c - E_F)}{k_B T}$$

(3)

$$N_c = 2 \left(\frac{2\pi m_n^2 k_B T}{A^2} \right)^{3/2}$$
 (4)

lub. eq. (8) in (1)
$$- nu_n f(x) = Dn \left[-\frac{n}{k_B T} \cdot e f(x) \right]$$

$$D_{n} = \frac{k_{B}T}{e} u_{n}$$

$$11 dy \quad \text{for halu} \quad D_{p} = \frac{k_{B}T}{e} u_{p}$$